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PATENT Attorney Docket No. 401479/Aoyama

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Art Unit: 2855

Examiner: Unassigned

In re Application of:

IZUO et al.

Application No. 10/009,521

Filed: December 11, 2001

For: METHOD AND APPARATUS FOR

RADIATION ASSISTED

ELECTROCHEMICAL ETCHING AND

ETCHED PRODUCT

REQUEST FOR CORRECTED OFFICIAL FILING RECEIPT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

An error has been noted on the Official Filing Receipt in the referenced application, namely, the fourth assignee's name is misspelled. Please issue a Corrected Official Filing Receipt correcting this error as marked in red on the attached copy of the Official Filing Receipt.

Respectfully submitted,

leffrey A. Wyand, Reg. No. 29,45

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Date Sujut He, 2003



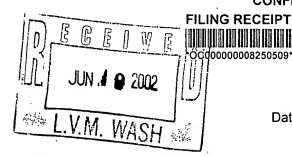
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	APPLICATION NUMBER	FILING DATE	GRP ART UNIT	FIL FEE REC'D	ATTY.DOCKET.NO	DRAWINGS	TOT CLAIMS	IND CLAIMS
_	10/009.521	12/11/2001	2855	974	401479	12	18	3

CONFIRMATION NO. 4369

23548 LEYDIG VOIT & MAYER, LTD 700 THIRTEENTH ST. NW SUITE 300 WASHINGTON, DC 20005-3960



Date Mailed: 06/13/2002

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Applicant(s)

Shinichi Izuo, Tokyo, JAPAN; Hiroshi Ohji, Tokyo, JAPAN; Kazuhiko Tsutsumi, Tokyo, JAPAN; Pattrick Jame French, Delft, NETHERLANDS;

Patrick James

Domestic Priority data as claimed by applicant

THIS APPLICATION IS A 371 OF PCT/JP00/03307 05/24/2000

Foreign Applications

Projected Publication Date: Not Applicable, filed prior to November 29,2000

Non-Publication Request: No

Early Publication Request: No

Title

Method and apparatus for radiation assisted electrochemical etching and etched product

Preliminary Class

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY.DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/009,521	12/11/2001	1742	1060	401479	12	18	3

CONFIRMATION NO. 4369

CORRECTED FILING RECEIPT

OC00000014297583

23548 LEYDIG VOIT & MAYER, LTD 700 THIRTEENTH ST. NW SUITE 300 WASHINGTON, DC 20005-3960

Date Mailed: 11/04/2004

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Applicant(s)

Shinichi Izuo, Tokyo, JAPAN; Hiroshi Ohji, Tokyo, JAPAN; Kazuhiko Tsutsumi, Tokyo, JAPAN; Patrick James French, Delft, NETHERLANDS;

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Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP00/03307 05/24/2000

Foreign Applications

If Required, Foreign Filing License Granted: 11/04/2004

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is US10/009,521

Projected Publication Date: None, application is not eligible for pre-grant publication

Non-Publication Request: No

Early Publication Request: No

Title

METHOD AND APPARATUS FOR RADIATION ASSISTED ELECTROCHEMICAL ETCHING AND ETCHED PRODUCT

Preliminary Class

205

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